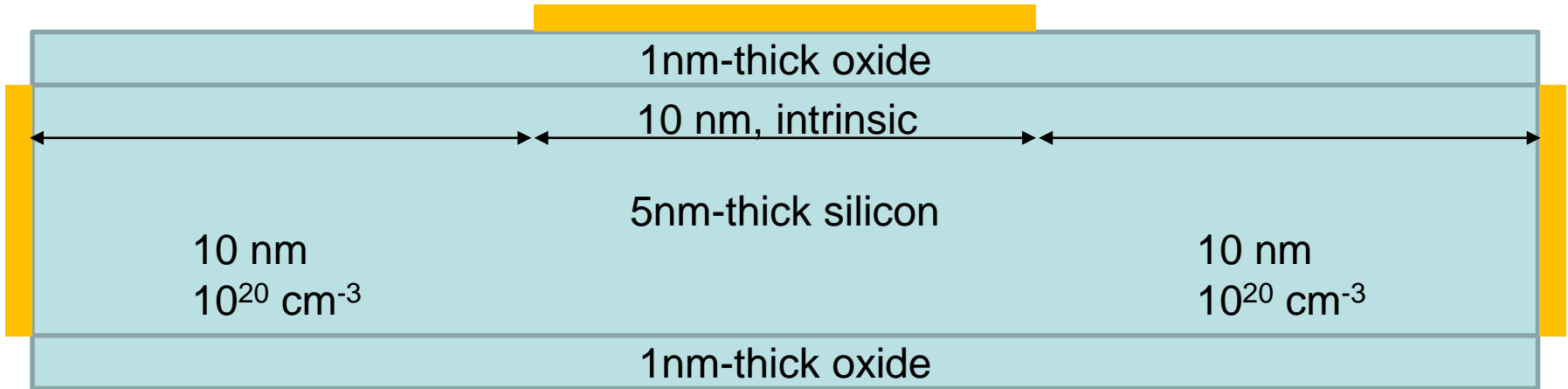

Lecture21

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Homework#17

- Due: AM08:00, November 23 (Next Monday)
- Problem#1
 - Calculate the I_D - V_D curve of the double-gate MOSFET. Consider several gate voltages (0 V ~ 1.1 V).



Finite volume method

- FEM is NOT used.
- The box method is used.

- Differential form

$$\nabla \cdot \mathbf{F} = s$$

- Integrated form

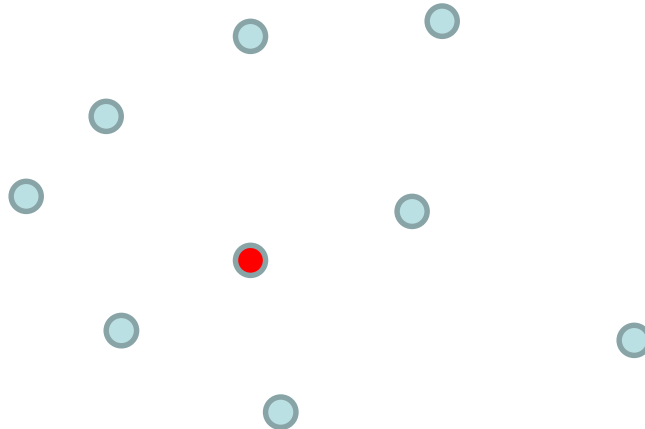
$$\oint_{\partial\Omega} \mathbf{F} \cdot d\mathbf{a} = \int_{\Omega} s d^3x$$

- Ω is the Voronoi cell.

- Delaunay mesh is needed!

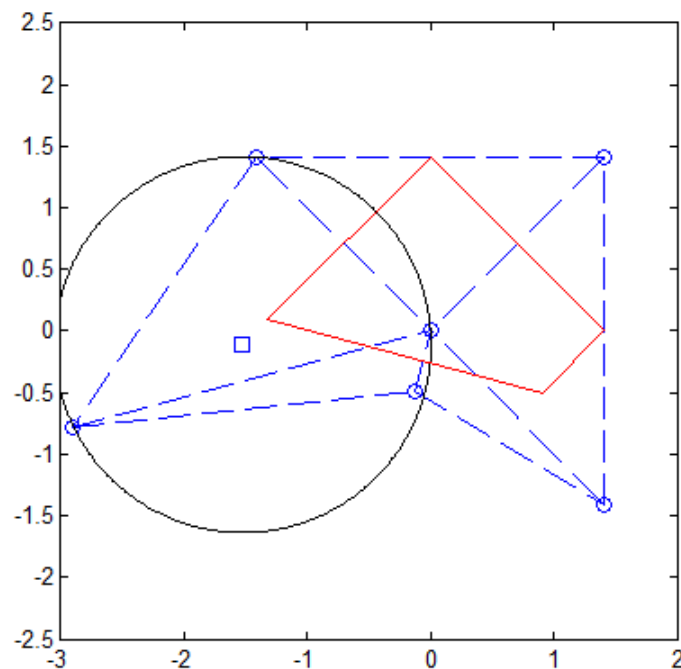
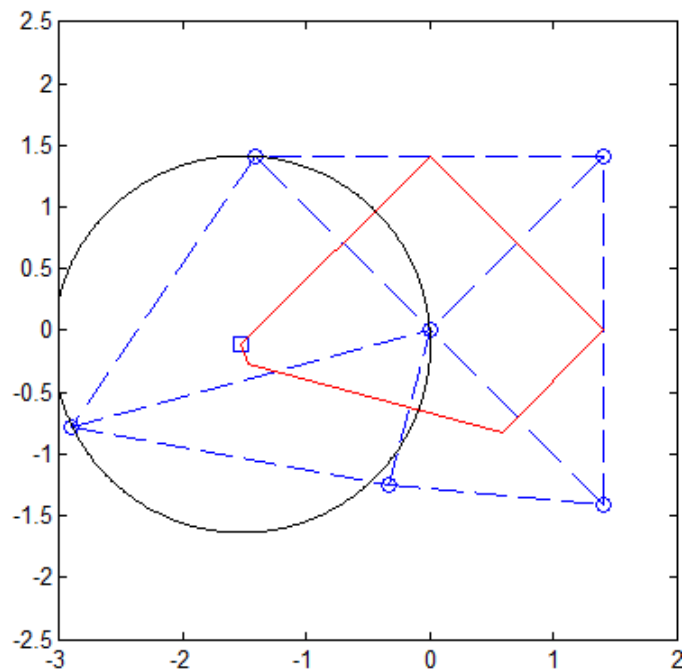
Voronoi volume

- Within the Voronoi volume of a center node, the closest node is the center node.
 - Calculating the plane (3D) or the line (2D), which is perpendicular to an edge and cross its mid-point



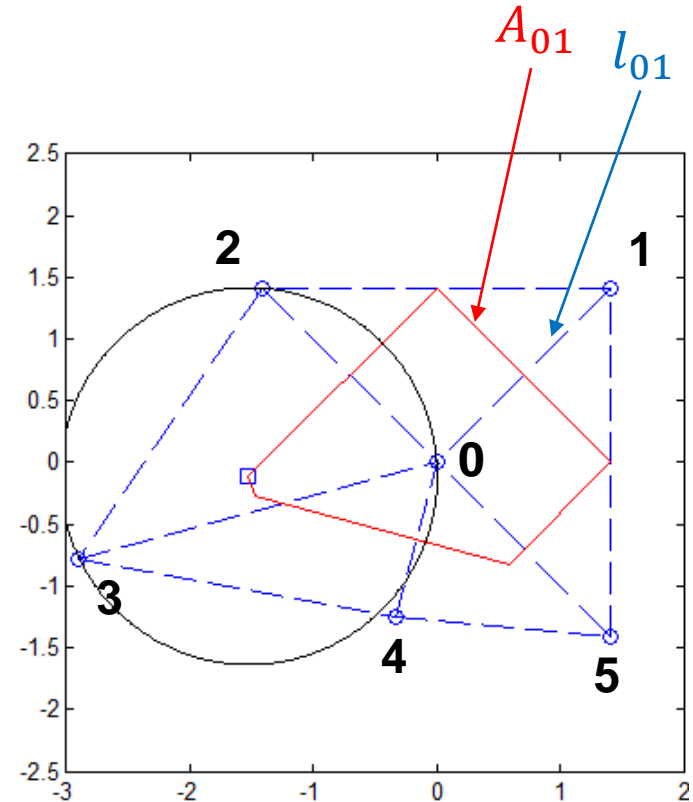
Pentagon examples

- Delaunay (Left) versus non-Delaunay (Right)



Poisson equation

- LHS, $\oint_{\partial\Omega} \mathbf{F} \cdot d\mathbf{a}$
 - It can be written as
$$\sum_{i=1}^5 F_{0i} A_{0i} = - \sum_{i=1}^5 \epsilon \frac{\phi_i - \phi_0}{l_{0i}} A_{0i}$$
 - We must calculate l_{0i} and A_{0i} .



Recipe

- For a 2D structure, it is not very difficult.
 - For each triangle whose side lengths are a, b , and c , calculate the circumradius, R .

$$Area = \frac{abc}{4R}$$

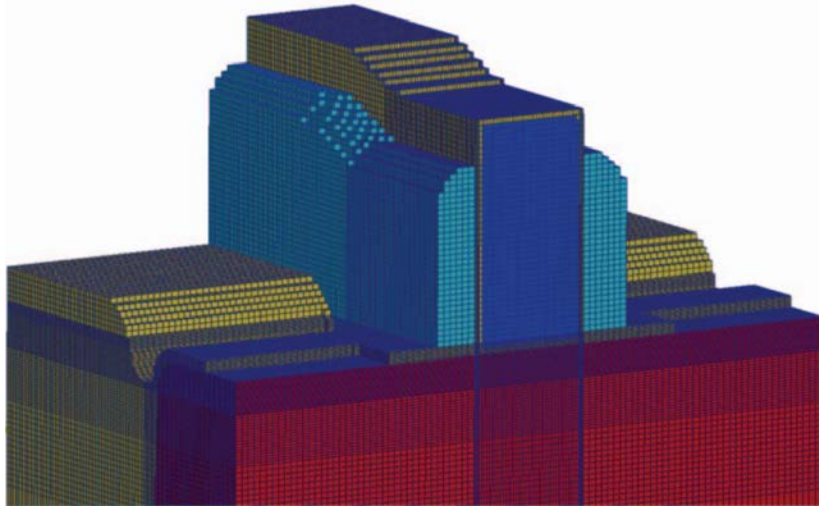
- From the circumcenter, by using the Pythagorean theorem,

$$R^2 = (A_{01,triangle})^2 + \left(\frac{l_{01}}{2}\right)^2$$

- How about an obtuse triangle?

3D mesh?

- Tetrahedron-based mesh
 - Difficult to calculate Voronoi cells
 - Structured grid cannot be used.



A structured grid (L. Wang et al., ULIS, 2014)

